



You are cordially invited to attend:

## **Atomic Force Microscopy (AFM) Metrology Workshop**

**Thursday, February 15, 2007**

**8:30 a.m. – 4:00 p.m.**

**Birck Nanotechnology Center (Room 2001)**

**No fee to attend. Seating is limited.**

**Please register online at: [www.veeco.com/afmworkshop](http://www.veeco.com/afmworkshop)**

**For more information, call (765) 496-1464.**

*Attend this free informative workshop to learn more about Atomic Force Microscopy and its ability to provide new insights to researchers around the world*

**8:30 — 8:45 a.m. Continental Breakfast and Welcome**

*Dr. Chris Getz, Midwest Account Manager, Veeco Instruments, Eden Prairie, MN*

**8:45 — 9:30 a.m. How Atomic Force Microscopy Is Advancing Life Science Research**

*Dr. Nelle Slack, Sr. Nano-Bio Scientist, Veeco Instruments, Santa Barbara, CA*

This session will present numerous applications to show the unique information that AFM can provide biologists, from imaging single molecules and tissue to visualization of real time events, such as molecular pulling, ligand/receptor interactions, membrane reorganization and cell signaling events. Included in this presentation will be the principles of AFM, focusing on primary imaging techniques used for biological samples as well as sample preparation, probe selection, and tips on data acquisition.

**9:30 — 10:15 a.m. Nanoscope V and Other New SPM Developments at Veeco**

*John Thornton, Sr. Scientist, Veeco Instruments, Chadds Ford, PA*

The progression of AFM development over the last few years has resulted in current instruments with a wider range of capabilities than their predecessors. The recent release of the NanoScope V controller has broadened the applications of AFM and produced a new platform for future developments. New features include capturing data at rates up to 50MHz, spring constant calibration up to 2MHz, Point and Shoot capability, high resolution data capture up to 5120 x 5120 pixels images, 3 independent lock-ins,

and 8 independent data channels. Other recent instrument developments, such as the Nanoman and PicoForce platforms, will also be discussed.

10:45 — 11:30 a.m. **Biological Atomic Force Microscopy Capabilities at Purdue University**

*Helen McNally, Ph.D. Assistant Professor, Department of Electrical and  
Computer Engineering Technology*

The capabilities and operation of the Biological Atomic Force Microscopy Laboratory will be described. An overview of ongoing projects will be provided, including research projects from the Colleges of Veterinary Medicine, Engineering and Agriculture.

11:30 — 1:00 p.m. **Lunch Provided by Veeco Instruments**

1:00 – 4:00 p.m. **BioScope II and MultiMode V AFM Instrument Demonstrations**

Elizabeth Ayres, AFM Research Technician, Bindley Bioscience Center  
Nelle Slack, John Thornton, Veeco Instruments

Spend some time in the afternoon observing these two instruments available for demonstrations in the Bindley Bioscience Center. Technicians will be available to answer questions and show you the latest applications for tools that can further your research expertise.

**BioScope II** (combines optical and AFM)

Bindley Bioscience Center  
Room 122

**MultiMode V PicoForce AFM**

(for single molecule interaction studies)

Bindley Bioscience Center  
Room 134

#### **WORKSHOP SPONSORS**

**Veeco** is a leading provider of Metrology and Process Equipment solutions used by manufacturers in the data storage, semiconductor and compound semiconductor/wireless industries. These industries help create a wide range of information age technology and products, such as personal computers and network servers, as well as newer technologies such as television set-top boxes, personal digital assistants and other consumer products. Our products are also critical enabling instruments used in the advancement of scientific research and nanotechnology. Veeco's Metrology tools are used to measure at the nanoscale and our Process Equipment tools help create nanoscale devices. Veeco partners with our global customers to deliver the enabling technology, experience and support they need to succeed.

